



## Supplement of

## Oxygenated products formed from OH-initiated reactions of trimethylbenzene: autoxidation and accretion

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Table S1 Relative abundance of the C9 and C18 oxidation products formed from TMB oxidation (Exp. #1-3 in Table 1), as measured by Nitrate CI-APi-TOF. The percentages mean the relative intensity of this compound family to the total signals of detected C9 and C18 products with correction of the relative transmission efficiency of Nitrate CI-APi-TOF obtained by the previously reported depletion method (Heinritzi et al., 2016). All of these products, except for  $C_9H_{14}O_5$  that was detected in the 1,2,4-TMB and 1,2,3-TMB experiments, have more than 6 oxygen atoms, which meet the definition of HOMs from Bianchi et al (2019).

Compound Family	1,3,5-TMB	1,2,4-TMB	1,2,3-TMB
$C_9H_{12}O_{6-11}$	1.9 %	6.6 %	7.5 %
$C_9H_{14}O_{5-11}$	5.9 %	10.2 %	18.3 %
$C_9H_{16}O_{6-10}$	5.7 %	9.6 %	11.8 %
$C_{18}H_{24}O_{8-13}$	3.2 %	4.9 %	4.0 %
$C_{18}H_{26}O_{8-15}$	33.4 %	23.1 %	26.5 %
$C_{18}H_{28}O_{9-15}$	44.9 %	39.0 %	26.9 %
$C_{18}H_{30}O_{12\text{-}15}$	5.1 %	6.6 %	5.0 %



**Figure S1.** Molecular structure of three partially deuterated precursors. (a) 1,2,4-(1-methyl-D3)-TMB; (b) 1,2,4-(2-methyl-D3)-TMB; and (c) 1,2,4-(4-methyl-D3)-TMB.



**Figure S2.** (a) Distribution of  $C_9H_xN_1O_y$  formed from 1,2,4-TMB under low NO<sub>x</sub> conditions, as detected by Nitrate CI-APi-TOF; and (b) Distribution of  $C_9H_xN_1O_y$  formed from 1,2,4-TMB under higher NO<sub>x</sub> conditions, as detected by Nitrate CI-APi-TOF.



**Figure S3.** (a) Distribution of  $C_9H_xN_2O_y$  formed from 1,2,4-TMB under low NO<sub>x</sub> conditions, as detected by Nitrate CI-APi-TOF; and (b) Distribution of  $C_9H_xN_2O_y$  formed from 1,2,4-TMB under higher NO<sub>x</sub> conditions, as detected by Nitrate CI-APi-TOF.

Section S1:

PAM \_chem\_v8 is a model developed in conjunction with the PAM, which includes the chemistry of photolysis of oxygen, water vapor, and other trace gases by the primary wavelengths in mercury lamps (254 nm and 185 nm) (Lambe et al., 2017; Li et al., 2015; Peng et al., 2015). Simplified VOC and RO<sub>2</sub> chemistry are also included, but the first-generation stabilized products and the second-generation organic radical products do not react further in the model.

Fig S4 shows the modelled concentration profiles of different oxidants and 1,3,5-TMB with an irradiance of  $1.64 \times 10^{15}$  ph cm<sup>-2</sup> s by 254 nm lamps. The initial concentrations of O<sub>3</sub> ([O<sub>3</sub>]) (1.2 ppm) and 1,3,5-TMB ([1,3,5-TMB]) were measured before turning on the 254 nm lamps. [O<sub>3</sub>] and [1,3,5-TMB], at an 80 s residence time were also measured The modelled [O<sub>3</sub>] is 20% lower than the measured value whereas modelled [1,3,5-TMB] is very close (4% higher) to the measured one, which shows the reliability of this model.



**Figure S4.** Concentration profiles of different oxidants and 1,3,5-TMB outputted by PAM\_chem\_v8 under the settings of Exp. #2. Initial [O<sub>3</sub>] and [1,3,5-TMB] are 1.2 ppm and 118 ppb, respectively, which were used as input of the model. The measured [O<sub>3</sub>] and [1,3,5-TMB] at the exit of OFR are shown by a triangle and a diamond, respectively. Input of irradiance of 254 nm lamps,  $I_{254}$ , is  $1.64 \times 10^{15}$  ph cm<sup>-2</sup> s, which was measured with a photodiode in the OFR. The vertical purple line represents a residence time of 80 s.

Figure S5 shows the modelled profiles of the major oxidants,  $NO_x$ , and the precursor under the settings of Exp. #7 and Exp. #8 in Table 1. In the low  $NO_x$  experiment, the modelled  $[O_3]$  is 20% lower than the measured value at the exit of OFR whereas the modelled [1,2,4-TMB] is 19% higher than the measured one. In the higher  $NO_x$  experiment, the modelled  $[O_3]$  is 3% higher than the measured value whereas the modelled [1,2,4-TMB] is 23% higher than the measured one.



**Figure S5.** Modelled profiles by PAM\_chem\_v8 of different oxidants, NO<sub>x</sub> and the precursor under the settings of (a) low NO<sub>x</sub> experiment (initial  $[O_3] = 1.8$  ppm, initial [1,2,4-TMB] = 170 ppb, and irradiance

of 254 nm Lamps =  $2.0 \times 10^{15}$  ph cm<sup>-2</sup> s) and (b) higher NO<sub>x</sub> experiment (initial [O<sub>3</sub>] = 6.7 ppm, initial [1,2,4-TMB] = 145 ppb, and irradiance of 254 nm Lamps =  $1.28 \times 10^{15}$  ph cm<sup>-2</sup> s). The measured [O<sub>3</sub>] and [1,2,4-TMB] at the exit of OFR are shown by a triangle and a diamond in the plot. The vertical purple line represents a residence time of 77.3 s.

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